

74

1/1 - (C) FILE HCAPLUS

STN CA Caesar accession number : 1293

AN - 2002:465605 HCAPLUS

DN - 137:34033

ED - Entered STN: 21 Jun 2002

TI - Antistatic agents and polycarbonate compositions containing them
with good transparency and impact resistanceIN - Sato, Ichiro; Nukui, Shinji; Shinohata, Masahiro; Kawakabe, Hiroshi;
Hara, Yoshifusa; Sugiya, Tadashi

PA - Sumitomo Dow Limited, Japan; Nippon Chemical Industrial Co., Ltd.

SO - Jpn. Kokai Tokkyo Koho, 6 pp.

CODEN: JKXXAF

DT - Patent

LA - Japanese

IC - ICM C08L069-00

ICS C08K005-50; C09K003-16

CC - 37-6 (Plastics Manufacture and Processing)

FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PN - JP2002173592	A2	20020621	JP 2000-391799	
				200012
				25

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PRAI- JP 2000-291725 A 20000926

CLASS

PATENT NO. CLASS PATENT FAMILY CLASSIFICATION CODES

JP 2002173592	ICM	C08L069-00
	ICS	C08K005-50; C09K003-16
	IPCI	C08L0069-00 [ICM,7]; C08K0005-50 [ICS,7]; C08K0005-00 [ICS,7,C*]; C09K0003-16 [ICS,7]
	IPCR	C09K0003-16 [I,C*]; C09K0003-16 [I,A]; C08K0005-00 [I,C*]; C08K0005-50 [I,A]; C08L0069-00 [I,C*]; C08L0069-00 [I,A]

OS - MARPAT 137:34033

AB - The antistatic agents comprise phosphonium salts R4P+ AF6- [R = (OH- or alkoxy-substituted) C1-18 alkyl, aryl, aralkyl; A = P, Sb]. Thus, a compn. contg. 100 parts Calibre 200-10 (bisphenol A-phosgene copolymer) and 2 parts tributyldodecylphosphonium hexafluorophosphate was injection-molded to give a test piece showing notched Izod impact strength (ASTM D 256) 80 kg-cm/cm, total light transmittance (ASTM D 1003) 89%, and surface resistivity 3 times. 1012 .OMEGA..

ST - antistatic agent polycarbonate phosphonium salt impact resistance; bisphenol phosgene polycarbonate butyldodecyl phosphonium fluorophosphate transparent

IT - Antistatic materials

Impact-resistant materials

(antistatic agents for polycarbonate compns. with good transparency and impact resistance)

IT - Polycarbonates, properties
RL: POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); USES (Uses)
(antistatic agents for polycarbonate compns. with good transparency and impact resistance)

IT - Phosphonium compounds
RL: MOA (Modifier or additive use); TEM (Technical or engineered material use); USES (Uses)
(antistatic agents; antistatic agents for polycarbonate compns. with good transparency and impact resistance)

IT - Antistatic agents
(phosphonium salts; antistatic agents for polycarbonate compns. with good transparency and impact resistance)

IT - 436799-10-9 436799-11-0 436799-12-1 436799-13-2 436799-14-3
436799-15-4
RL: MOA (Modifier or additive use); TEM (Technical or engineered material use); USES (Uses)
(antistatic agent; antistatic agents for polycarbonate compns. with good transparency and impact resistance)

IT - 24936-68-3, Calibre 200-10, properties 25971-63-5, Bisphenol A-phosgene copolymer
RL: POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); USES (Uses)
(antistatic agents for polycarbonate compns. with good transparency and impact resistance)

AN - 2002:465605 HCPLUS

DN - 137:34033

TI - Antistatic agents and polycarbonate compositions containing them with good transparency and impact resistance

IN - Sato, Ichiro; Nukui, Shinji; Shinohata, Masahiro; Kawakabe, Hiroshi; Hara, Yoshifusa; Sugiya, Tadashi

PA - Sumitomo Dow Limited, Japan; Nippon Chemical Industrial Co., Ltd.

SO - Jpn. Kokai Tokkyo Koho, 6 pp.
CODEN: JKXXAF

DT - Patent

LA - Japanese

FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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PN - JP2002173592	A2	20020621	JP 2000-391799	200012 25
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PRAI- JP 2000-291725 A 20000926

OS - MARPAT 137:34033

AB - The antistatic agents comprise phosphonium salts R₄P⁺ AF₆⁻ [R = (OH- or alkoxy-substituted) C₁₋₁₈ alkyl, aryl, aralkyl; A = P, Sb]. Thus, a compn. contg. 100 parts Calibre 200-10 (bisphenol A-phosgene copolymer) and 2 parts tributylodecylphosphonium hexafluorophosphate was injection-molded to give a test piece showing notched Izod impact strength (ASTM D 256) 80 kg-cm/cm, total

light transmittance (ASTM D 1003) 89%, and surface resistivity 3 times. 1012 .OMEGA..

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Switching to CAPLUS

Switching to ZREGISTRY

Display of compounds in JP2002173592

? ..li hitstr 1-1

1/1 - (C) FILE CAPLUS

IT - 436799-10-9 436799-11-0 436799-12-1
 436799-13-2 436799-14-3 436799-15-4

RL: MOA (Modifier or additive use); TEM (Technical or engineered material use); USES (Uses)

(antistatic agent; antistatic agents for polycarbonate compns. with good transparency and impact resistance)

RN - 436799-10-9 CAPLUS

CN - Phosphonium, tributylhexadecyl-, hexafluorophosphate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 17895-73-7

CMF C24 H52 P

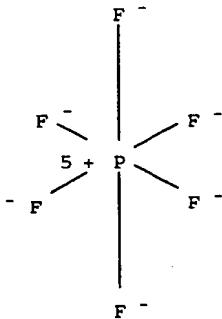
Me — (CH₂)₁₁ — P + (Bu-n)₃

CM 2

CRN 16919-18-9

CMF F6 P

CCI CCS



RN 436799-11-0 CAPLUS

CN Phosphonium, tributylhexadecyl-, hexafluorophosphate(1-) (9CI) (CA INDEX NAME)

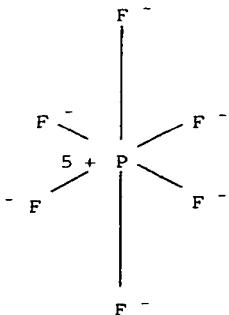
CM 1

CRN 66997-36-2
CMF C28 H60 P

Me — (CH₂)₁₅ — P⁺ (Bu-n)₃

CM 2

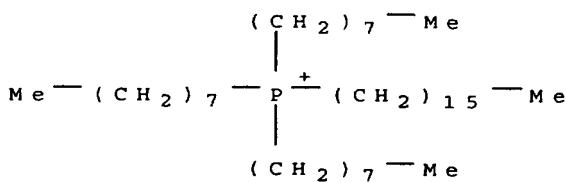
CRN 16919-18-9
CMF F6 P
CCI CCS



RN 436799-12-1 CAPLUS
CN Phosphonium, hexadecyltrioctyl-, hexafluorophosphate(1-) (9CI) (CA INDEX NAME)

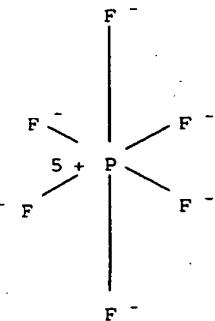
CM 1

CRN 125652-20-2
CMF C40 H84 P



CM 2

CRN 16919-18-9
CMF F6 P
CCI CCS



RN 436799-13-2 CAPLUS

CN Phosphonium, tributylhexadecyl-, (OC-6-11)-hexafluoroantimonate(1-)
(9CI) (CA INDEX NAME)

CM 1

CRN 66997-36-2

CMF C28 H60 P

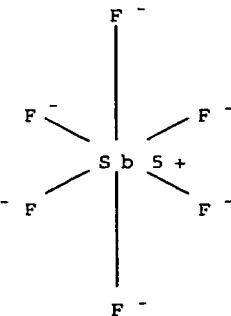
Me — (CH₂)₁₅ — P⁺ (Bu-n)₃

CM 2

CRN 17111-95-4

CMF F6 Sb

CCI CCS



RN 436799-14-3 CAPLUS

CN Phosphonium, tributylhexadecyl-, (OC-6-11)-hexafluoroantimonate(1-)
(9CI) (CA INDEX NAME)

CM 1

CRN 17895-73-7

CMF C24 H52 P

Me — (CH₂)₁₁ — P⁺ (Bu-n)₃

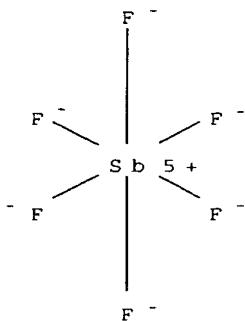
BEST AVAILABLE COPY

CM 2

CRN 17111-95-4

CMF F6 Sb

CCI CCS



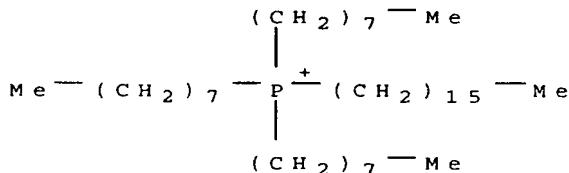
RN 436799-15-4 CAPLUS

CN Phosphonium, hexadecyltriocetyl-, (OC-6-11)-hexafluoroantimonate(1-)
(9CI) (CA INDEX NAME)

CM 1

CRN 125652-20-2

CMF C40 H84 P

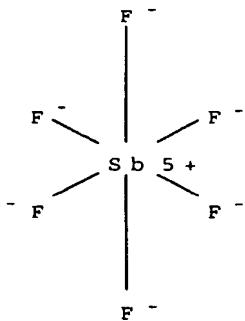


CM 2

CRN 17111-95-4

CMF F6 Sb

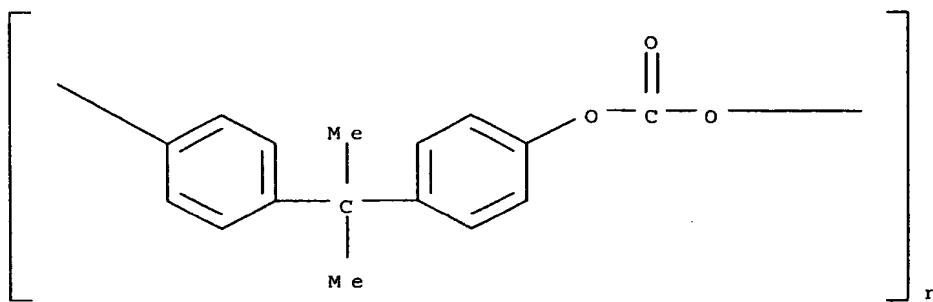
CCI CCS



IT ***24936-68-3*** , Calibre 200-10, properties ***25971-63-5*** ,
Bisphenol A-phosgene copolymer
RL: POF (Polymer in formulation); PRP (Properties); TEM (Technical
or engineered material use); USES (Uses)
(antistatic agents for polycarbonate compns. with good
transparency and impact resistance)

RN 24936-68-3 CAPPLUS

CN Poly[oxycarbonyloxy-1,4-phenylene(1-methylethyldene)-1,4-phenylene]
(9CI) (CA INDEX NAME)



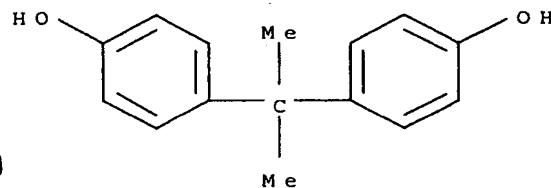
RN 25971-63-5 CAPPLUS

CN Carbonic dichloride, polymer with 4,4'-(1-methylethyldene)bis[phenol] (9CI) (CA INDEX NAME)

CM 1

CRN 80-05-7

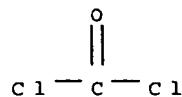
CMF C15 H16 O2



CM 2

CRN 75-44-5

CMF C C12 O



? Display of structures from JP2002173592 complete

Switched back to HCAPPLUS

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